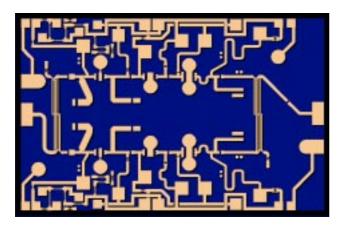


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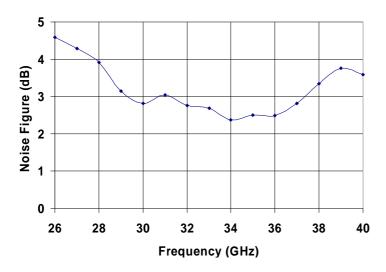
#### 30-38 GHz Balanced Low Noise Amplifier

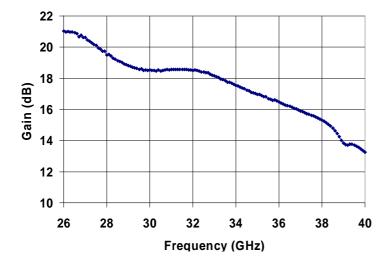
**TGA4511-EPU** 



#### **Preliminary Measured Data**

Bias Conditions: Vd = 3.5 V, Id = 110 mA





#### **Key Features**

- 0.15 um pHEMT Technology
- 15 dBm Nominal Pout @ 35 GHz
- 17 dB Nominal Gain @ 35 GHz
- 2.5 dB Noise Figure @ 35 GHz
- Bias Conditions: 3.5V, 110 mA
- Chip Dimensions: 2.7mm x 1.8mm

#### **Primary Applications**

- Point-to-Point Radio
- Point-to-Multipoint Radio



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# TABLE I MAXIMUM RATINGS 5/

SYMBOL	PARAMETER	VALUE	NOTES		
V <sup>+</sup>	Positive Supply Voltage	6 V	<u>4/</u>		
V	Negative Supply Voltage Range	-2 to 0 V			
I <sup>+</sup>	Positive Supply Current (Quiescent)	400 mA	<u>4/</u>		
I <sub>G</sub>	Gate Supply Current	40 mA			
P <sub>IN</sub>	Input Continuous Wave Power	TBD			
$P_{D}$	Power Dissipation	TBD	<u>3</u> / <u>4</u> /		
T <sub>CH</sub>	Operating Channel Temperature	150 <sup>0</sup> C	<u>1</u> / <u>2</u> /		
T <sub>M</sub>	Mounting Temperature (30 Seconds)	320 °C			
T <sub>STG</sub>	Storage Temperature	-65 to 150 °C			

- 1/ These ratings apply to each individual FET.
- <u>2</u>/ Junction operating temperature will directly affect the device median time to failure (T<sub>M</sub>). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 3/ When operated at this bias condition with a base plate temperature of TBD, the median life is reduced from TBD to TBD.
- 4/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P<sub>D</sub>.
- 5/ These ratings represent the maximum operable values for this device.

# TABLE II ELECTRICAL CHARACTERISTICS

 $(Ta = 25^{\circ}C \pm 5^{\circ}C)$ 

PARAMETER	TYPICAL	UNITS	
Drain Operating	3.5	V	
Quiescent Current	110	mA	
Small Signal Gain	17	dB	
Input Return Loss (Linear Small Signal)	18	dB	
Output Return Loss (Linear Small Signal	18	dB	
Output Power @ 1 dB Compression Gain	15	dBm	
Third Order Intercept Point @ -12 dBm @ 35GHz	25	dBm	

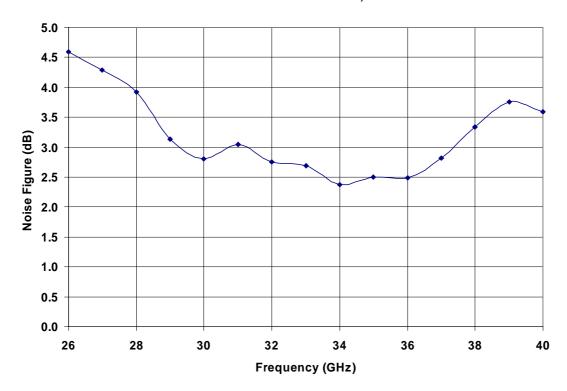


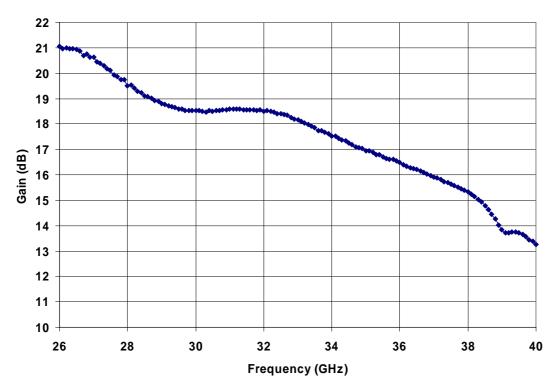
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## **Preliminary Measured Data**

Bias Conditions: Vd = 3.5 V, Id = 110 mA





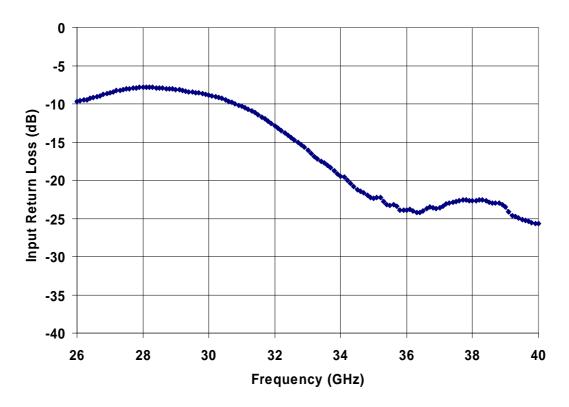


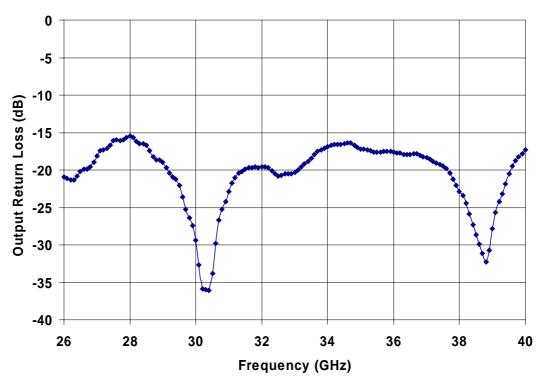
**November 2, 2004** 

**TGA4511-EPU** 

## **Preliminary Measured Data**

Bias Conditions: Vd = 3.5 V, Id = 110 mA





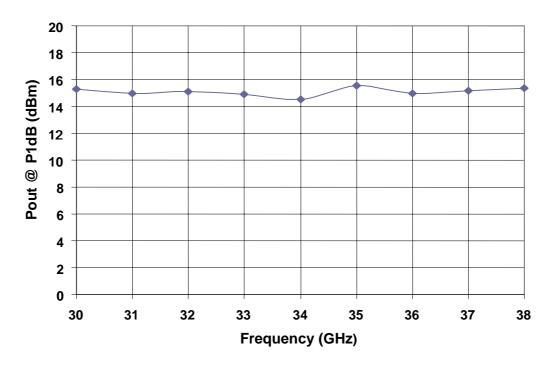


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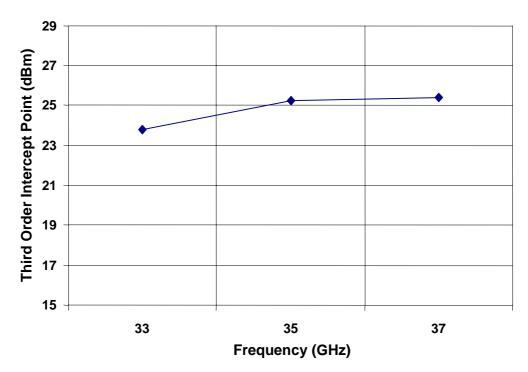
**TGA4511-EPU** 

## **Preliminary Measured Data**

Bias Conditions: Vd = 3.5 V, Id = 110 mA



TOI at -12 dBm Input Power (P1dB - 10 dB)

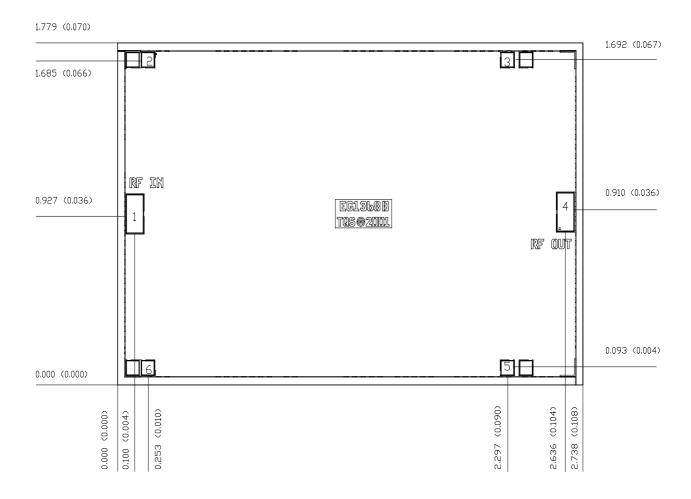




#### Advance Product Information November 2, 2004

**TGA4511-EPU** 

## **Mechanical Drawing**



Units: millimeters (inches) Thickness: 0.1016 (0.004)

Chip edge to bond pad dimensions are shown to center of bond pad Chip size tolerance:  $\pm -0.051$  (0.002)

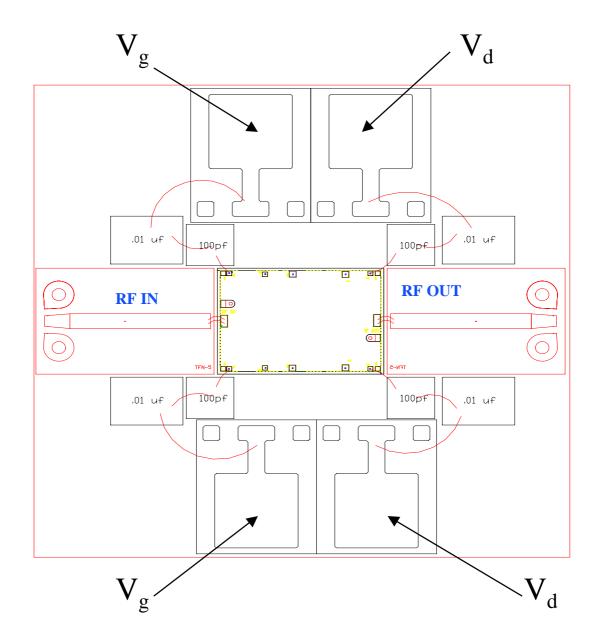
Bond pad	#1	(RF In)	0.100	×	0.200	(0.004 ×	(	(800.0
Bond pad	#2	(Vg)	0.085	X	0.085	(0.003	X	0.003)
Bond pad	#3	(/ q)	0.085	X	0.085	(0.003	X	0.003)
Bond pad	#4	(RF Out)	0.100	X	0.200	(0.004	×	(800.0
Bond pad	#5	(Vd)	0.085	×	0.085	(0.003	X	0.003)
Bond pad	#6	(Vg)	0.085	X	0.085	(0.003	X	0.003)



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## **Chip Assembly Diagram**



GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.



# Advance Product Information November 2, 2004 TGA4511-EPU

#### **Assembly Process Notes**

#### Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300 □ C.
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

#### Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

#### Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Discrete FET devices with small pad sizes should be bonded with 0.0007-inch wire.
- Maximum stage temperature is 200 □ C.

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.